

Harsh Environment Silicon Carbide Sensor Technology for Geothermal Instrumentation

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High Temperature Tools and Sensors,
Down-hole Pumps and Drilling

- **Timeline**
 - Project start date: 01/29/2010
 - Project end date: 02/28/2013
 - Percent complete: 5%
- **Budget**
 - Total project funding: \$2,222,022
 - DOE share: \$1,777,617
 - Awardee share: \$444,405
- **Barriers**
 - Development of tools and sensors capable of tolerating the extreme environment of supercritical reservoirs (374°C and 220 bar for pure water).
- **Partners**
 - Not Applicable

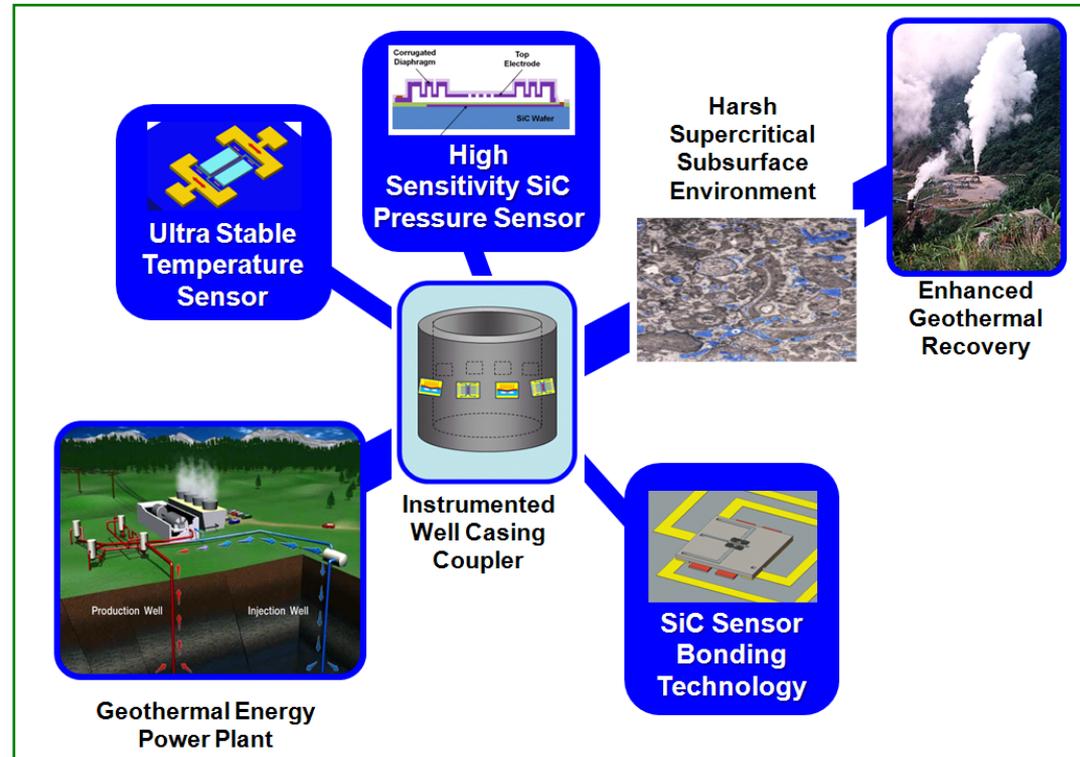
- Project objectives:
 - Develop advanced sensor technology for the direct monitoring of geothermal reservoirs.
 - Engineer sensors to survive and operate in H₂O pressures up to 220 bar and temperatures as high as 374°C.
- Innovative aspects of project:
 - Utilize chemically inert and thermally stable materials (ceramic, wide-band gap materials and inert metals)
 - Utilize semiconductor manufacturing technology to create sensors
 - Develop capacitive-based sensors that can interface with simple electronics.

Property	Silicon Carbide 3C-SiC (6H-SiC)	AlN	Silicon	Diamond
Melting Point (°C)	2830 (2830) sublimes	2470	1420	4000 phase change
Energy Gap (eV)	2.4 (3.0)	6.2	1.12	5.6
Critical Field ($\times 10^6$ V/cm)	2.0 (2.5)	10	0.25	5.0
Thermal Conductivity (W/cm-K)	5.0 (5.0)	1.6	1.5	20
Young's Modulus (GPa)	450 (450)	340	190	1035
Acoustic Velocity ($\times 10^3$ m/s)	11.9 (11.9)	11.4	9.1	17.2
Yield Strength (GPa)	21 (21)	-	7	53
Coeff. of Thermal Expansion ($^{\circ}\text{C} \times 10^{-6}$)	3.0 (4.5)	4.0	2.6	0.8
Chemical Stability	Excellent	Good	Fair	Fair

Material properties of SiC and other materials used by the semiconductor industry.

Phase I:

- **Task 1:** Deliver Preliminary Pressure Sensor (Design #1) for Operation in Harsh Subsurface Environments
- **Task 2:** Deliver Preliminary Temperature Sensor (Design #1) for Operation in Harsh Subsurface Environments
- **Task 3:** Develop and Complete Preliminary Characterization of the Bonding Procedure for Adhering Sensors to Casing Components
- **Task 4:** Perform Supercritical Exposure Demonstrations on Sensor Materials



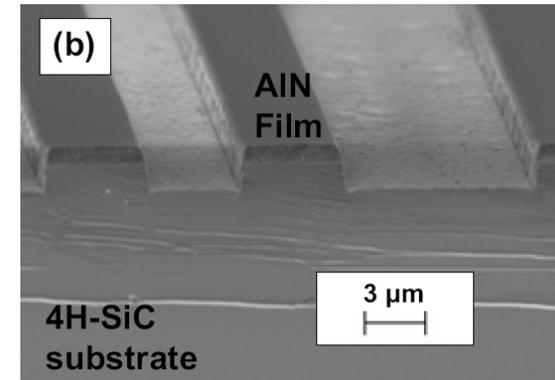
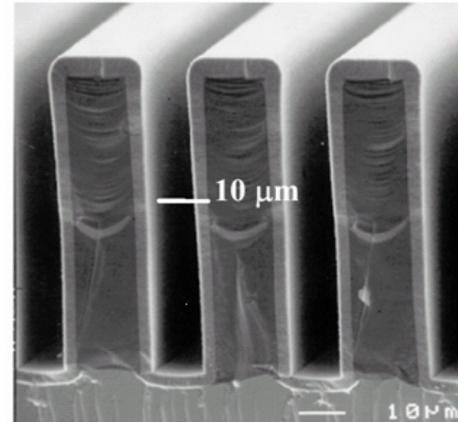
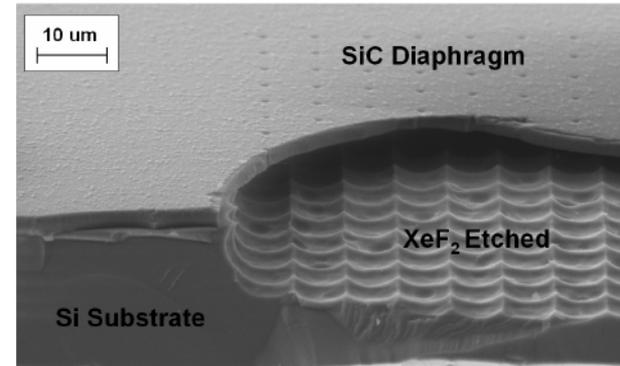
- Progress to date
 - Preliminary design algorithms for capacitive SiC temperature sensor developed
 - Fabrication process for sensors developed
 - Design of experiments for Y1 exposure tests developed
- Planned accomplishments/outcomes
 - Exposure testing of materials in supercritical environments
 - Design and fabrication of pressure and temperature sensors
 - Development of harsh environment bonding technology



Experimental Petrology Laboratory
(Prof. Hammer – U of Hawaii)

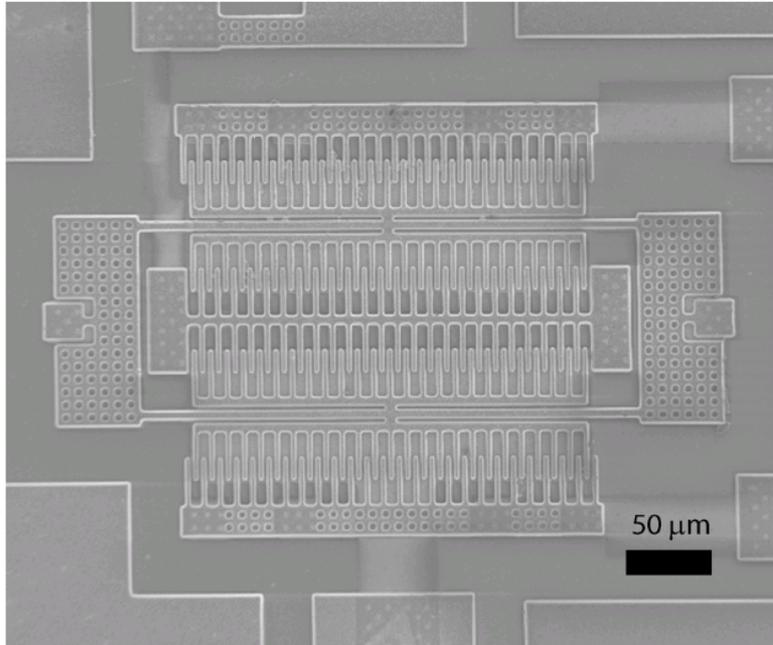
**Image of high pressure vessel
(max. pressure = 3500 bars at
600°C) to be used for supercritical
exposure testing.**

- Special process equipment available at UC Berkeley (Micro and Nano Laboratories)
 - Low pressure chemical vapor deposition (LPCVD) of polycrystalline 3C-SiC
 - Ion sputter deposition of amorphous SiC
 - Reactive sputtering of aluminum nitride (AlN)
 - Plasma etching of SiC

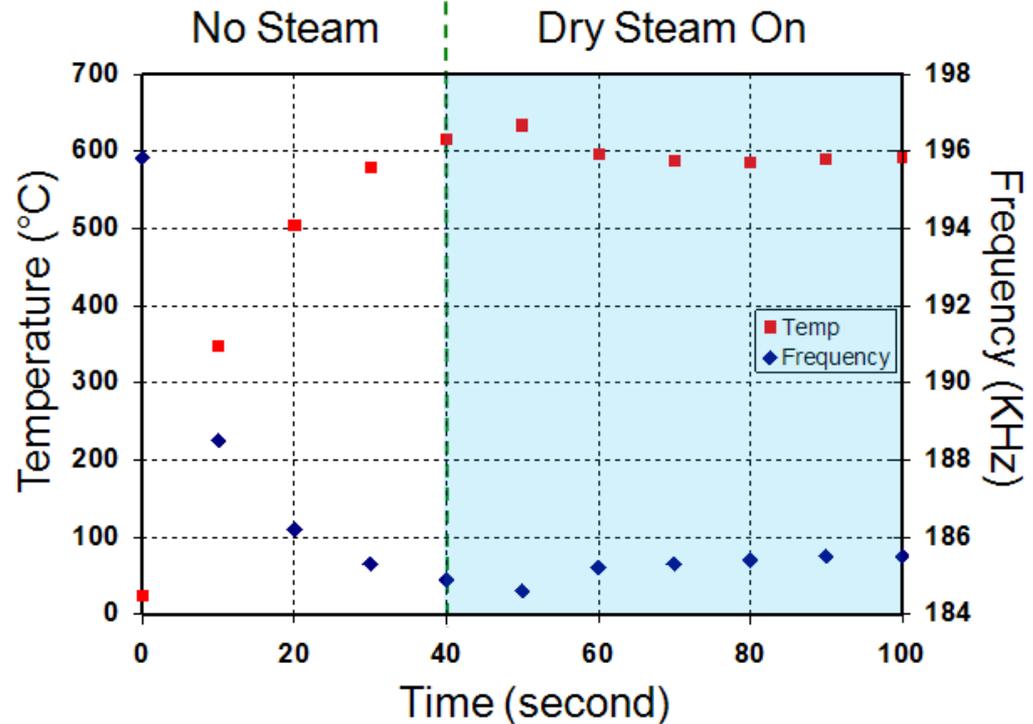


Images of SiC structures fabricated at UC Berkeley by researchers in Prof. Maboudian and Prof. Pisano laboratories.

Accomplishments, Expected Outcomes and Progress



SEM image of polycrystalline 3C-SiC (7μm thick) resonant strain sensor fabricated at UC Berkeley.



Results of high-temperature exposure testing of SiC strain sensor.

D. R. Myers et al., J. Micro/Nanolith. MEMS MOEMS (2009)

- Y1 Research Schedule
 - Supercritical exposure testing of materials (June 2010)
 - Design optimization of sensors (July 2010)
 - Fabrication of sensors (October 2010)
 - Experimental testing and characterization of first generation sensors (December 2010)
- Application of resources and leveraged funds/budget/spend plan
 - 1 Research specialist
 - 3 Graduate student researchers (GSRs)
 - User facilities
 - Microlaboratory (UC Berkeley)
 - Petrology laboratory (University of Hawaii)

- Future research
 - Development of parametric design models of mechanical sensors (pressure and temperature)
 - In-situ exposure testing of materials and sensors in experimental supercritical environments
 - Demonstrate sensor bonding technology on casing components
- Development or deployment needs
 - Collaborations for future field testing are desired

- Development of advanced sensor technology for in-situ geothermal reservoir monitoring is underway
- Materials will be exposed to supercritical environments for extended periods
- SiC pressure and temperature sensors will be designed to monitor the reservoir environment
- Harsh environment bonding technology will be developed to locate sensors within the harsh reservoir environment